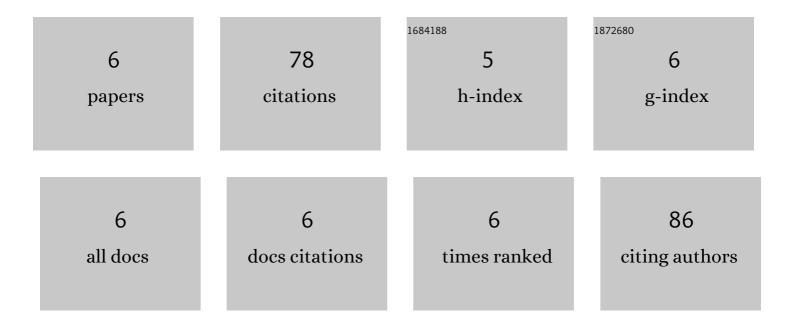
Abdullah H Alshehri

List of Publications by Year in descending order

Source: https://exaly.com/author-pdf/11379447/publications.pdf Version: 2024-02-01



#	Article	IF	CITATIONS
1	Nanoscale Film Thickness Gradients Printed in Open Air by Spatially Varying Chemical Vapor Deposition. Advanced Functional Materials, 2021, 31, 2103271.	14.9	8
2	Metalâ€Insulatorâ€Insulatorâ€Metal Diodes with Responsivities Greater Than 30 A W ^{â^'1} Based on Nitrogenâ€Doped TiO <i>_x</i> and AlO <i>_x</i> Insulator Layers. Advanced Electronic Materials, 2021, 7, 2100467.	5.1	7
3	Metal-Insulator-Metal Diodes: Quantum-Tunneling Metal-Insulator-Metal Diodes Made by Rapid Atmospheric Pressure Chemical Vapor Deposition (Adv. Funct. Mater. 7/2019). Advanced Functional Materials, 2019, 29, 1970042.	14.9	1
4	Near zero-bias MIIM diode based on TiO2/ZnO for energy harvesting applications. AIP Advances, 2019, 9, .	1.3	18
5	Quantumâ€Tunneling Metalâ€Insulatorâ€Metal Diodes Made by Rapid Atmospheric Pressure Chemical Vapor Deposition. Advanced Functional Materials, 2019, 29, 1805533.	14.9	39
6	Simple plasma assisted atomic layer deposition technique for high substitutional nitrogen doping of TiO2. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2018, 36, 031602.	2.1	5